

The “Important Project of Common European Interest” (IPCEI) in Microelectronics

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*A new path for investment in research, development and
innovation by Europe’s semiconductor industry*

Klaus Pressel (Infineon), Rainer Pforr (Zeiss), and Michael Offenbergl (Bosch)

Outline

- History and motivation
- The five technology fields
- Investment in Europe
- Modelling and simulation: Enablers to improve technology
- Conclusions

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- **History and motivation**
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In 2012 the European Commission defined the Key Enabling Technologies (KETs)

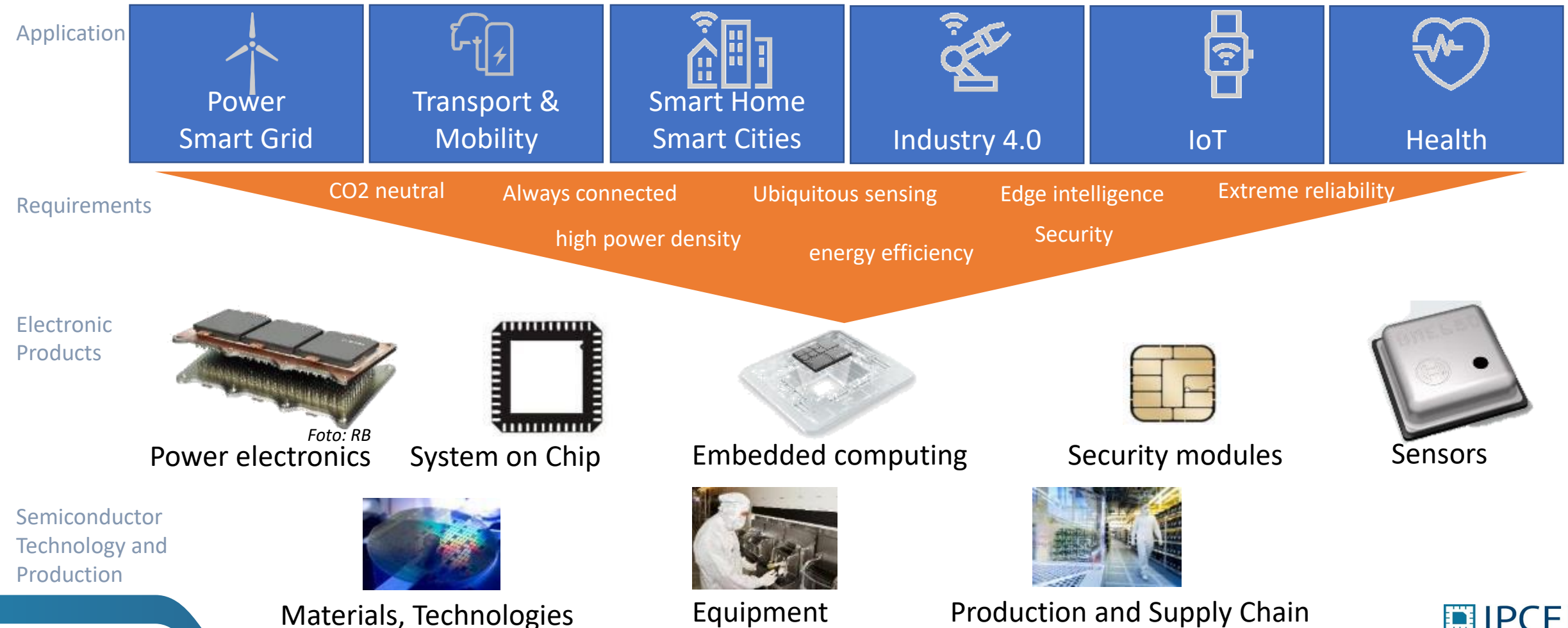
This KETs-based product is defined by the European Commission Communication (COM (2012) 341) as follows (European Commission 2012c):

- a) an enabling product for the development of goods and services enhancing their overall commercial and social value
- b) induced by constituent parts that are based on nanotechnology, micro-/nanoelectronics industrial biotechnology, advanced materials and/or photonics and, but not limited to
- c) produced by advanced manufacturing technologies

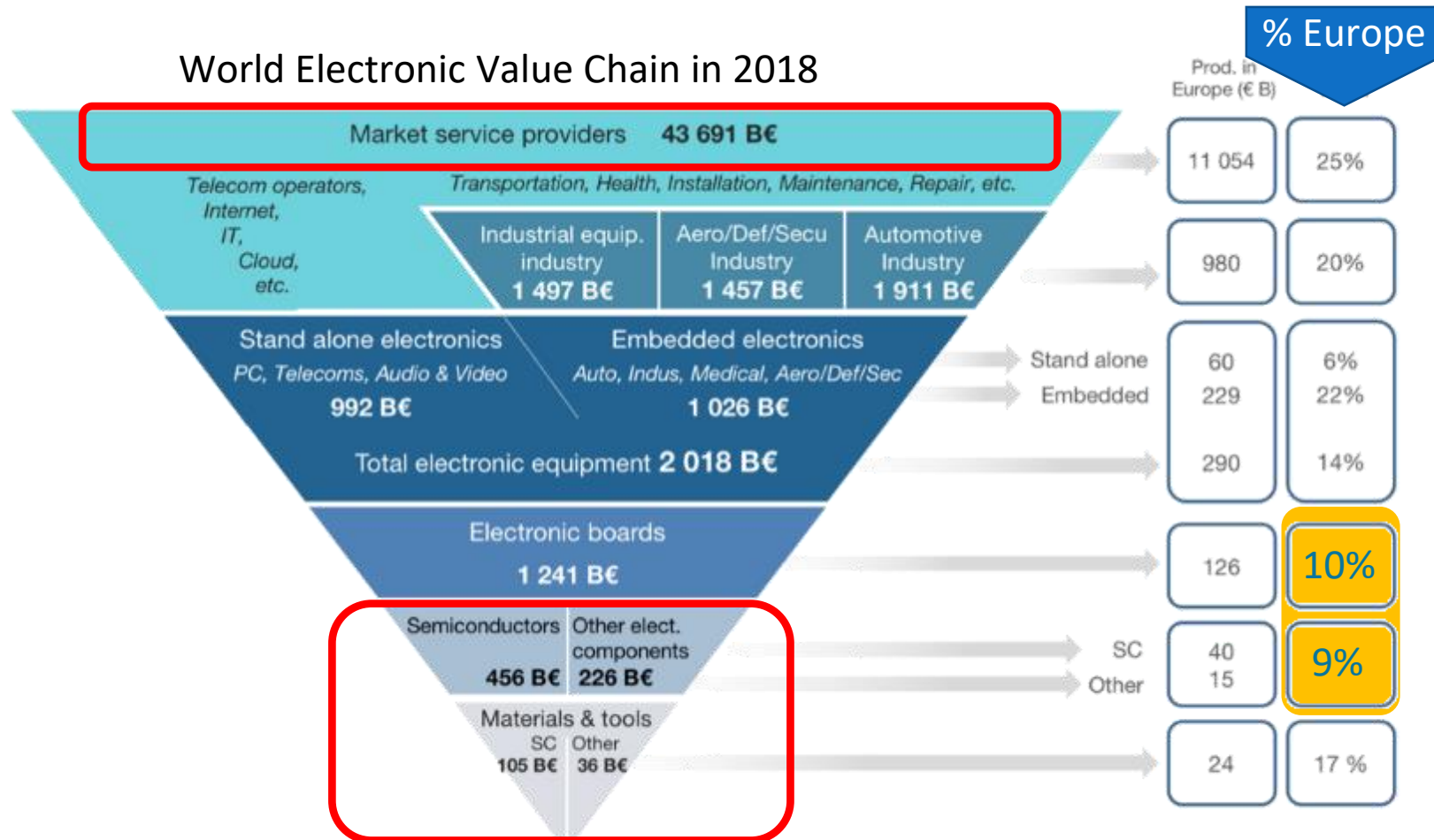
=> Micro-/Nanoelectronics was identified as one of the key enabler

- ECSEL JU was founded - focuses on Research & Development & Innovation and on pilot lines (**access to technology**), but, during ramp up a lot of issues need to be addressed e.g. stability of processes, understanding of small effects and their impact on reliability, quality and yield
- Thus, starting from 2014 the new funding tool “**Important Project of Common European Interest (IPCEI)**” has been introduced in Europe (**first industrial deployment, FID**)
- A first project has been launched by the European semiconductor industry in early 2017
- After notification by the European Commission end of 2018 this project type is now in place and the accompanying companies push this further throughout Europe

Microelectronics is a key technology for meeting challenges of the application domains in a CO2 neutral and digital society



World Electronic Value Chain in 2018



European strengths (examples)

Vehicles, Industry, **Medical** Equipment

Automotive systems, Medical, Industry

SoC, smart power, sensors, security, μ C

Manufacturing mixed signal >22nm, Special (MEMS, SiC, Power)

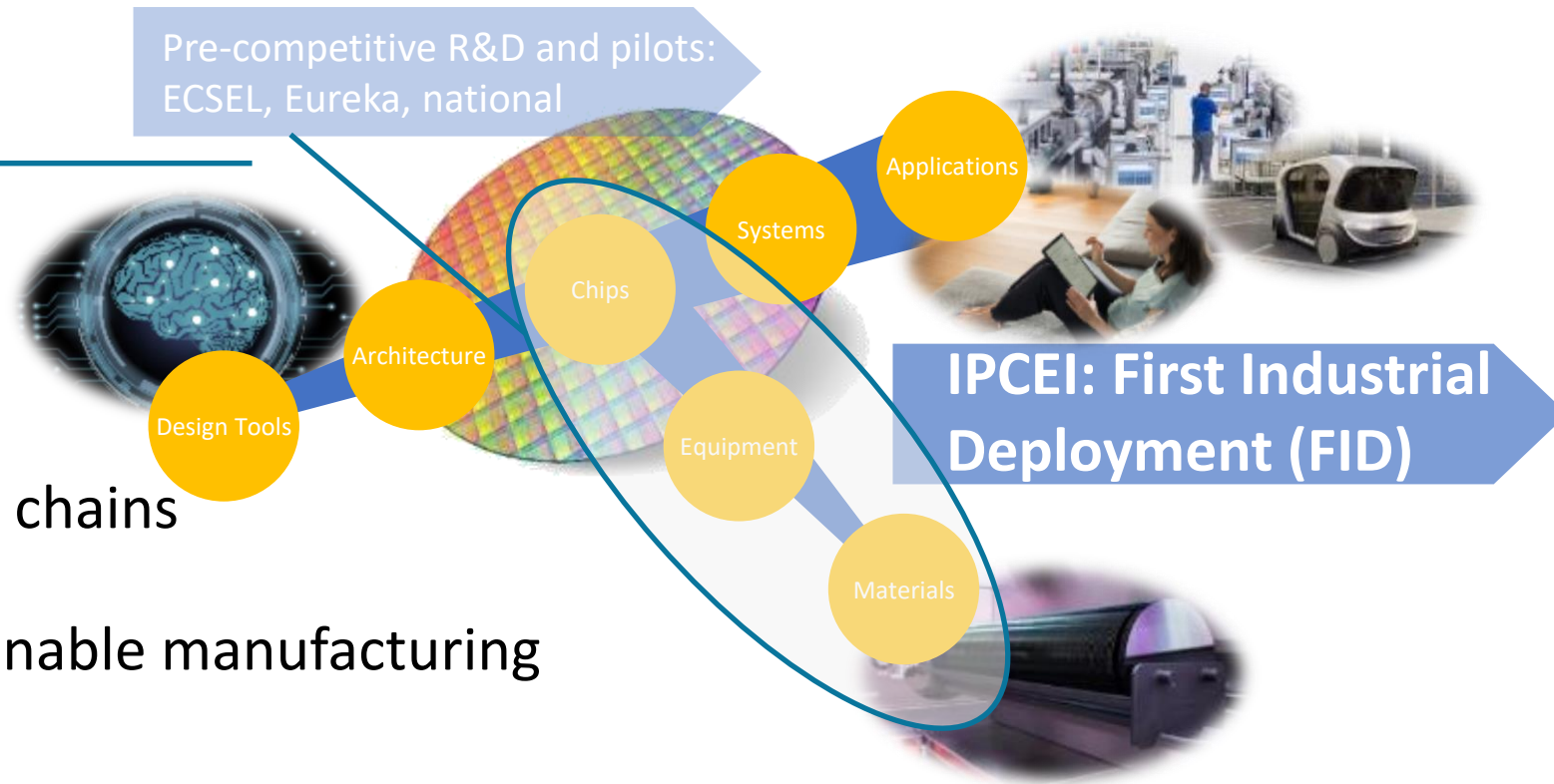
Tools, Lithography, Automation

Source : DECISION for the study: Emerging Technologies in Electronic Components and Systems - Opportunities Ahead (DG CONNECT, 2019)

IPCEI 2017 – 2020 (2022)

Objectives

- Enabling strategic European value chains
- R&D, innovation and strong sustainable manufacturing
- Global competitiveness
- Trustability and sovereignty



Sources: Bosch, deposit photos

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The 5 “Technology Fields” of the IPCEI for Microelectronics

1. Energy efficient chips (e.g. ultra-low power FDSOI and embedded digital technologies)
2. Power Semiconductors (e.g. innovative silicon as well as new materials (GaN, SiC), assembly & packaging)
3. Smart Sensors (e.g. mm-wave sensors for autonomous driving and sensors for IoT applications)
4. Advanced Optical Equipment (e.g. leading edge optics for More Moore devices)
5. Compound materials (e.g. next generation lighting systems applying LEDs)

The five technology fields

Project management				
1 Energy efficient chips	2 Power semiconductors	3 Sensors	4 Advanced optical equipment	5 Compound materials
CEA-Leti 	3-D Micromac 	CEA-Leti 	AMTC 	AZUR Space Solar Power 
Cologne Chip 	AP&S International 	CorTec 	Carl Zeiss* 	CEA-Leti 
Globalfoundries 	CEA-Leti 	Elmos Semiconductors 		Integrated Compound Semiconductors 
Racy/CS 	Elmos Semiconductors 	Fondazione Bruno Kessler 		IQE* 
Soitec* 	Infineon* 	Infineon 		Newport Wafer Fab 
ST Micro-electronics 	MURATA 	Robert Bosch* 		SPTS Technologies 
X-FAB 	Robert Bosch 	ST Micro-electronics 		OSRAM 
	SEMIKRON 	TDK-Micronas 		Sofradir* 
	ST Micro-electronics 	ULIS* 		Soitec 
	X-FAB 	X-FAB 		ST Micro-electronics 
* Coordinator				
Dissemination and communication				

* Now Lynred

- + 4 EU countries
- + 27 project partners
- + Focus on 5 Technology Fields
- + Projects costs ≥ 6 bn€
- + Total funding about 1.75bn€
- + Funding per national government only

The five technology fields

Project management				
1 Energy efficient chips	2 Power semiconductors	3 Sensors	4 Advanced optical equipment	5 Compound materials
CEA-Leti	3-D Micromac	CEA-Leti	AMTC	AZUR Space Solar Power
Cologne Chip	AP&S International	CorTec	Carl Zeiss*	CEA-Leti
Globalfoundries	CEA-Leti	Elmos Semiconductors		Integrated Compound Semiconductors
Racy/CS	Elmos Semiconductors	Fondazione Bruno Kessler		IQE*
Soitec*	Infineon*	Infineon		Newport Wafer Fab
ST Micro-electronics	MURATA	Robert Bosch*		SPTS Technologies
X-FAB	Robert Bosch	ST Micro-electronics		OSRAM
	SEMIKRON	TDK-Micronas		Sofradir*
	ST Micro-electronics	ULIS*		Soitec
	X-FAB	X-FAB		ST Micro-electronics
Dissemination and communication				

* Now Lynred

11 presentations in this EuroSimE

8 partners involved

All technology fields involved

Introduction to importance of modelling and simulation in IPCEI

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First Industrial Deployment in Europe: Some Highlights



Fab extension at Soitec Crolles



ST at Crolles



ST at Atrate



Fab extension at Zeiss Oberkochen



New Bosch fab at Dresden



Infineon at Warstein



Fab extension Infineon at Regensburg

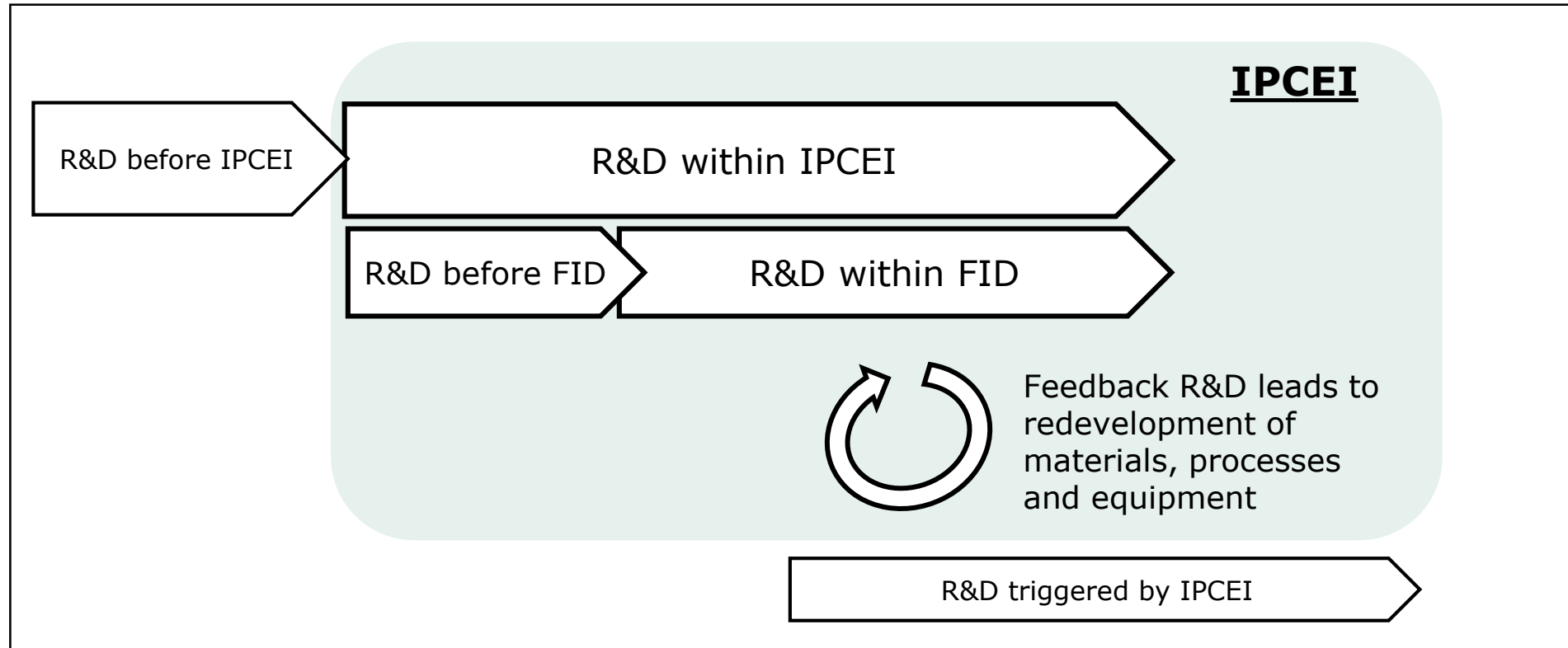


Globalfoundries at Dresden

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The need for ever more R & D & I in FID



- FA4.0 – innovative Failure Analysis (German-French EUREKA Euripides/Penta – Project),
driven especially by IPCEI partners Infineon, Bosch, ST-F, ...
- iRel40 - Intelligent Reliability (76 partners from 13 European countries in one ECSEL JU project drive reliability along the value chain),
driven especially by IPCEI partners Infineon, Bosch, XFAB, Elmos, ...

10 technical presentations from five technology fields

Project management				
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	ST Micro-electronics	ULIS*		Soitec
	X-FAB	X-FAB		ST Micro-electronics
Dissemination and communication				

* Coordinator

* Now Lynred

1 overview presentation

10 technical presentations in this EuroSimE

8 partners involved

All technology fields involved

Target of this session

Introduction to importance of modelling and simulation in IPCEI

“Introduction to the Important Project of Common European Interest (IPCEI) – A new path for investment in research, development and innovation by Europe’s semiconductor industry”, (# 107)

Corresp. author: Klaus Pressel (Infineon), Rainer Pforr (Zeiss), Michael Offenberg (Bosch)

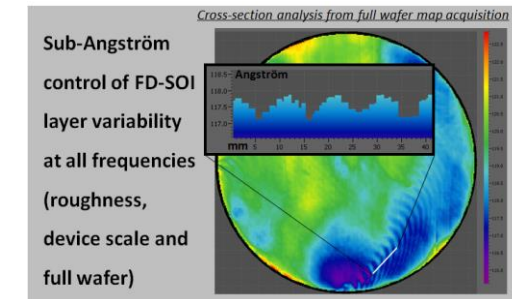
Email: klaus.pressel@infineon.com

Technology Field 1: Energy Efficient Chips

“Differential Réflective Metrology: An innovative variability measurement for advanced FDSOI material” (# 108)

Corresp. author: Jean-Michel Billiez, Walter Schwarzenbach (Soitec, France)

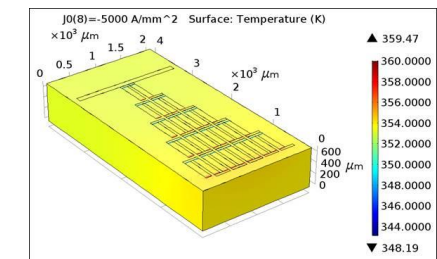
Email: jean-michel.billiez@soitec.com



“Thermal-electric modelling of thermoelectric and electrocaloric on-chip cooling devices” (# 109)

Corresp. author: Caroline Schwinge, Sabine Kolodinsky, Maciej Wiatr, M. Wagner-Reetz, W. Weinreich (Fraunhofer IPMS and GLOBALFOUNDRIES Dresden)

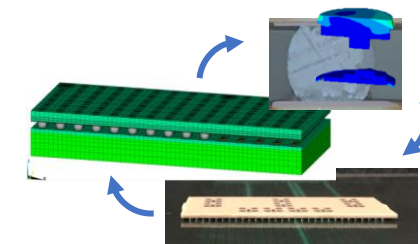
Email: caroline.schwinge@ipms.fraunhofer.de



“Finite Element Simulation for High Frequency Automotive Package Developments” (# 110)

Corresp. author: Karsten Meier, L. Wamberra, C. Götze, M. Wieland, K. Bock (Techn. Univ. Dresden and GLOBALFOUNDRIES Dresden)

Email: karsten.meier@tu-dresden.de

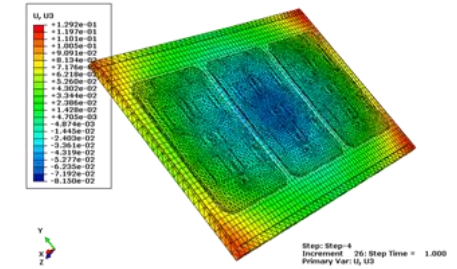


Technology Field 2: Power Semiconductors

“Power Module Ceramic Substrates: mechanical characterization and modeling” (# 111)

Corresp. author: Michele Calabretta (STMicroelectronics Italy)

Email: michele.calabretta@st.com



AMB substrate out of plane displacement and the interaction with assembly

“Reliability Requirements of Advanced Packaging in the Era of Electrified, Automated and Connected Driving” (# 112)

Corresp. author: Przemyslaw Gromala (Bosch)

Email: PrzemyslawJakub.Gromala@de.bosch.com

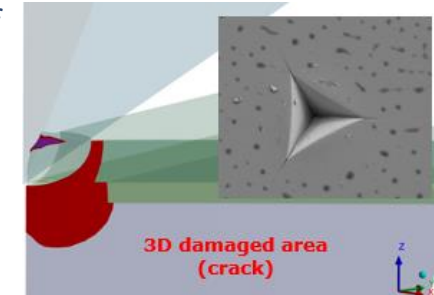
“FEM simulation applied to Thermal Laser Separation (TLS) with Deep Scribe for Silicon Wafer Dicing” (# 114)

Corresp. author: Christian Belgardt (3D-Micromac AG)

Email: belgardt@3d-micromac.com

Technology Field 3: Smart Sensors

Reliable method for determination of fracture properties allows to avoid over-engineering in design of robust micro-electronic structures (Ananiev et al)



“Determination of Fracture Properties of Thin Dielectric Films by Nanointendation” (# 113)

Corresp. author: Sergey Ananiev , P. Altieri-Weimar (both Infineon), C. Sander, A. Clausner (both FhG IKTS)

Email: Sergey.Ananiev@infineon.com

“Trends and future challenges in designing and simulating high performance MEMS” (# 115)

Corresp. author: Mirko Hofmann (Bosch)

Email: Mirko.Hofmann@de.bosch.com

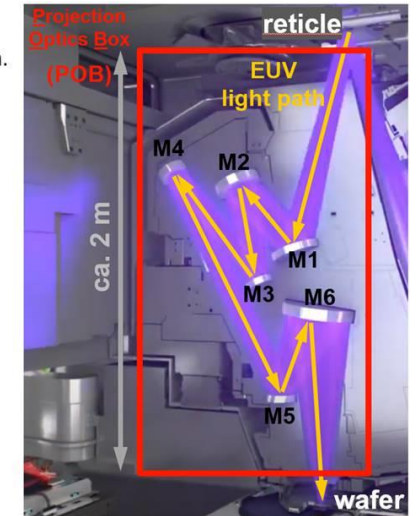
Technology Field 4 Optical Equipment

“Transient Thermoelastic Structure Analysis to quantify the Thermal Stability of Extreme-Ultraviolet (EUV) Projection Systems”
(# 116) Corresponding author: Timo Laufer (Zeiss)

Email: timo.laufer@zeiss.com

Heat impact on Projection Optics Box (POB) about 90 W.
Dimension mirror support structure (POB-frame) about 2 m.
The **thermal stability** of the mirror support structure must guarantee an image drift on wafer level of less than 1 nm within the exposure of one wafer (within about 1 min).

→ **Stability Requirement:**
Image drift on wafer level < 1 nm / min !!!



Technology Field 5: Compound Materials

"Innovative relaxed InGaN engineered substrates for RGB Micro-LEDs" (# 117)
Corresponding authors: David SOTTA (SOITEC) and Amelie DUSSAIGNE (CEA-LETI)

Email: david.sotta@soitec.com

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- IPCEI on Microelectronics is a great success for the European Semiconductor Industry !
 - Stimulating substantial investment
 - Jobs and Know-How in Europe
- International challenges remain, have even increased
- Europe has strong opportunities in emerging microelectronics technologies needed to serve megatrends and achieve societal goals
- IPCEI Microelectronic served as a blueprint for follow-up IPCEIs: [European Battery Alliance](#) and [Clean Hydrogen Alliance](#)

IPCEI is an important tool to bring technology to the level of First Industrial Deployment and should be pushed and further developed.

Thank you

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for making this EuroSimE session happen

And now enjoy the 10 presentations on modelling and simulation
from the five IPCEI technology fields